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(71) Applicant (for all designated States except US): **INTENSE PHOTONICS LIMITED** [GB/GB]; 4 Stanley Boulevard, Hamilton International Technology Park, High Blantyre, Glasgow G72 0BN (GB).

(72) Inventor; and

(75) Inventor/Applicant (for US only): **NAJDA, Stephen, Peter** [GB/GB]; 8/6 Fleming House, 134 Renfrew Street, Glasgow G3 6ST (GB).

(74) Agent: **CHARIG, Raymond**; Eric Potter Clarkson, Park View House, 58 The Ropewalk, Nottingham NG1 5DD (GB).

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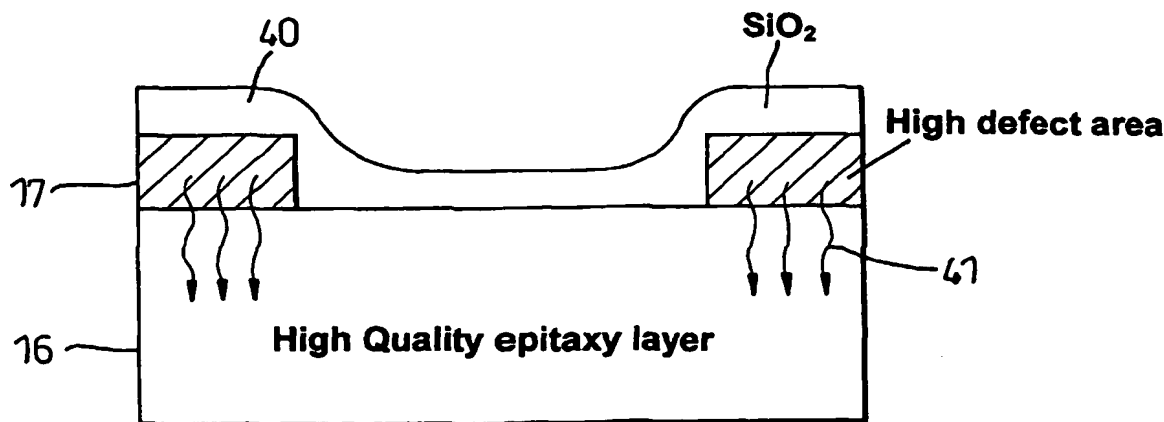
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(54) Title: **QUANTUM WELL INTERMIXING IN SEMICONDUCTOR PHOTONIC DEVICES**



(57) Abstract: A method for fabricating a semiconductor device in a semiconductor structure, provides enhanced quantum well intermixing in desired regions of the device by forming a first, relatively high quality, epitaxial layer on a substrate, the high quality layer including a quantum well; forming a second, relatively lower quality, epitaxial defect layer on top of the high quality layer; and thermally processing the structure to effect at least partial diffusion of the defects from the defect layer into the high quality layer in order to achieve quantum well intermixing in the structure. The use of an epitaxially grown defect layer on top of, or within, a high quality epitaxially grown device body enables quantum well intermixing techniques to be performed at lower temperatures and thereby improves device characteristics.

# INTERNATIONAL SEARCH REPORT

International Application No

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A. CLASSIFICATION OF SUBJECT MATTER  
IPC 7 H01S5/34

According to International Patent Classification (IPC) or to both national classification and IPC

## B. FIELDS SEARCHED

Minimum documentation searched (classification system followed by classification symbols)  
IPC 7 H01L H01S

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the international search (name of data base and, where practical, search terms used)

EPO-Internal

## C. DOCUMENTS CONSIDERED TO BE RELEVANT

Category *	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	US 2002/127752 A1 (LEE ALEX S W ET AL) 12 September 2002 (2002-09-12) paragraphs '0006!, '0008!, '0019! - '0022!, '0033!	1-3,7,8, 13,21-25
X	LEE A S W ET AL: "Enhanced band-gap blueshift due to group V intermixing in InGaAsP multiple quantum well laser structures induced by low temperature grown InP" APPLIED PHYSICS LETTERS, AMERICAN INSTITUTE OF PHYSICS. NEW YORK, US, vol. 78, no. 21, 21 May 2001 (2001-05-21), pages 3199-3201, XP012028077 ISSN: 0003-6951 the whole document	1,8, 21-25

☒ Further documents are listed in the continuation of box C.

☒ Patent family members are listed in annex.

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Name and mailing address of the ISA

European Patent Office, P.B. 5818 Patentlaan 2,  
NL - 2280 HV Rijswijk  
Tel. (+31-70) 340-2040, Tx. 31 651 epo nl,  
Fax: (+31-70) 340-3016

Authorized officer

Claessen, L

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## C.(Continuation) DOCUMENTS CONSIDERED TO BE RELEVANT

Category *	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
A	US 2002/072142 A1 (HO SENG-TIONG ET AL) 13 June 2002 (2002-06-13) the whole document	1,4-6
A	LI A T H ET AL: "WAVEGUIDING IN VERTICAL CAVITY QUANTUM-WELL STRUCTURE DEFINED BY ION IMPLANTATION" JOURNAL OF LIGHTWAVE TECHNOLOGY, IEEE. NEW YORK, US, vol. 16, no. 8, 1 August 1998 (1998-08-01), pages 1498-1508, XP000786585 ISSN: 0733-8724 the whole document	1,13,14
A	US 5 534 444 A (BENSOUSSAN MARCEL ET AL) 9 July 1996 (1996-07-09) the whole document	1-25
A	US 5 708 674 A (THORNTON ROBERT L ET AL) 13 January 1998 (1998-01-13) the whole document	1-25

# INTERNATIONAL SEARCH REPORT

International Application No

/GB 03/04705

Patent document cited in search report	Publication date	Patent family member(s)	Publication date
US 2002127752 A1	12-09-2002	US 2002030185 A1	14-03-2002
		US 2003071265 A1	17-04-2003
		AU 5207101 A	26-11-2001
		WO 0188993 A2	22-11-2001
		CA 2343694 A1	19-11-2001
US 2002072142 A1	13-06-2002	WO 0235589 A1	02-05-2002
		AU 1321602 A	06-05-2002
US 5534444 A	09-07-1996	FR 2721752 A1	29-12-1995
		DE 69502347 D1	10-06-1998
		DE 69502347 T2	11-02-1999
		EP 0689253 A1	27-12-1995
		JP 8051245 A	20-02-1996
US 5708674 A	13-01-1998	JP 8236860 A	13-09-1996
		US 5843802 A	01-12-1998